

Title (en)

Device and method for cleaning mostly level surfaces

Title (de)

Vorrichtung und Verfahren zum Reinigen weitgehend ebener Flächen

Title (fr)

Dispositif et procédé destinés à nettoyer des surfaces principalement planes

Publication

**EP 1972246 B1 20100616 (DE)**

Application

**EP 08001327 A 20080124**

Priority

DE 102007013343 A 20070320

Abstract (en)

[origin: EP1972246A1] The device has a housing (1) comprising a wiper blade (4) on a side, and a wiper block (3) for simultaneous supplying to a surface (7) to be cleaned. A side skirt (5) is provided on the housing, and laterally closes a space between the surface and the housing, and the wiper blade and the wiper block. The housing covers the wiper blade up to its front edge (8), and forms a guide edge (6), which pushes the wiper blade over its entire length against the surface to be cleaned. An independent claim is also included for a method for cleaning a level surface i.e. window.

IPC 8 full level

**A47L 1/06** (2006.01)

CPC (source: EP)

**A47L 1/06** (2013.01)

Cited by

AT15667U1; AT15667U8; CN113693485A; WO2016071135A1

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